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APPLICATION NO.	FILING DATE	FIRST NAMED II	NVENTOR		ATTORNEY DOCKET NO.
09/777,922	02/07/01	KOHASHI		I	925-175
-		halbalen a steer en en			EXAMINER
MM91/0907 NIXON & VANDERHYE P.C.			HARMON, C		
1100 NORTH				ART UNIT	PAPER NUMBER
ARLINGTON V	A 22201-4/1	4		2881	
				DATE MAILED	:
					09/07/01

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

17

·		Application No.	plicant(s)				
Office Action Summary			KOHASHI, IKUO				
		09/777,922					
		Examiner	Art Unit				
1		David A. Zarneke	2812				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 1 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status							
1) 🗌	Responsive to communication(s) filed o	n					
2a) 🗌	This action is FINAL . 2b)	This action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Disposition	on of Claims						
4)⊠ Claim(s) <u>1-9</u> is/are pending in the application.							
4a) Of the above claim(s) is/are withdrawn from consideration.							
5) Claim(s) is/are allowed.							
6) Claim(s) is/are rejected.							
7) Claim(s) is/are objected to.							
8) Claims 1-9 are subject to restriction and/or election requirement.							
Application	on Papers						
9) The specification is objected to by the Examiner.							
10) The drawing(s) filed on is/are objected to by the Examiner.							
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved.							
12) The oath or declaration is objected to by the Examiner.							
Priority u	nder 35 U.S.C. \$ 119						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. ≸ 119(a)-(d) or (f).							
a) ☐ All b) ☐ Some * c) ☐ None of:							
1. Certified copies of the priority documents have been received.							
2. Certified copies of the priority documents have been received in Application No							
3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
14) Acknowledgement is made of a claim for domestic priority under 35 U.S.C. § 119(e).							
Attachment		, ¬	Comment (DTO 442) Paper No(6)				
15) Notice of References Cited (PTO-892) 18) Interview Summary (PTO-413) Paper No(s) 19) Notice of Informal Patent Application (PTO-152) 17) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 20) Other:							

Application/Control Number: 09/777,922

Art Unit: 2812

DETAILED ACTION

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- I. Claims 1-3, drawn to a semiconductor laser apparatus, classified in class 372, subclass 1+.
- II. Claims 4-9, drawn to a method of producing a semiconductor laser apparatus, classified in class 438, subclass 26.

The inventions are distinct, each from the other because of the following reasons:

Inventions I and II are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case, the process as claimed can be practiced by another materially different apparatus. For example, the specifics of the apparatus claim are not required in the process claim, specifically the height requirement of the paste in the apparatus claim.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.



Art Unit: 2812

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David A. Zarneke whose telephone number is (703)-305-3926. The examiner can normally be reached on M-Th (7:30-6:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Niebling can be reached on (703)-308-3325. The fax phone numbers for the organization where this application or proceeding is assigned are (703)-308-7722 for regular communications and (703)308-7721 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)-308-0956.

David A. Zarneke

June 8, 2001